## PATENT ABSTRACTS OF JAPAN

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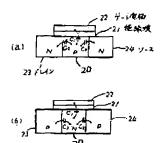
(21)Application number: 61-107609 (71)Applicant: TOSHIBA CORP (22)Date of filing: 13.05.1986 (72)Inventor: OWAKI YUKITO

## (54) MOS TYPE FIELD EFFECT TRANSISTOR

## (57) Abstract:

PURPOSE: To obtain an element having an excellent cut-off characteristic because of its low threshold value at an ON time and its high threshold value at an OFF time, by varying the potential of a channel forming part of MOSFET in coupling with a gate potential.

CONSTITUTION: A capacity between a P region 20 forming a channel of MOSFET and a gate electrode 22 provided on said region with an insulating film 21 interposed between is denoted by C1, and a floating capacity between the P region 20 and a drain electrode 23 and a source electrode 24 is denoted by C2. When a gate potential is varied in an amplitude from O to VG, the potential of an N-type substrate rises from an inner potential VBϕ to VBϕ+{[C1/(C1 + C2)].VG} by coupling. When Nch-FET is ON, concretely, a threshold value lowers with the rise of the substrate potential, while the threshold value rises when the gate potential is varied from VG to 0 so as to turn FET OFF, and thus a sufficient current cut-off characteristic is obtained. The same operation is shown also in the case of Pch-FET. This method is effective also for FET of a SOI structure provided on an insulator. A floating capacity in a channel forming region is still smaller in this case, and therefore the effect is made easy to realize.



## **LEGAL STATUS**

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